

# CIP 09

17<sup>th</sup> International Colloquium on Plasma Processes  
Marseille, France

## MONDAY, JUNE 22

### COURSES

- 8.30 am **Welcome participants**
- 9.00 am **Introduction to cold plasmas**  
T. Gans - Univ. Belfast, UK
- 10.30 am **Coffee Break**
- 10.45 am **Advanced plasma diagnostics for thin film deposition: in situ studies**  
R. van de Sanden - Univ. Eindhoven, The Netherlands
- 12.15 am **Lunch (organised by SFV)**
- 2.00 pm **Physical Vapour Deposition of thin films: from DC to High-Power Impulse Magnetron Sputtering**  
S. Konstantinidis - Univ. Mons, Belgium
- 3.30 pm **Coffee Break**
- 3.45 pm **Plasma etching for microelectronics and nano-microtechnology**  
C. Cardinaud - Univ. Nantes, France

## TUESDAY, JUNE 23

- 9.00 am **Plasma chemistry, plasma surface interaction and thin film deposition in PECVD**  
J. Benedikt - Univ. Bochum, Germany
- 10.30 am **Coffee Break**
- 10.45 am **Plasma treatment of polymeric surfaces and applications to biomaterials engineering**  
F. Poncin Epailard - Univ. du Maine, Le Mans, France
- 2.00 pm Introduction to the Conference**